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(54) **METHOD OF MANUFACTURING AN ALUMINIUM ALLOY PLATE FOR VACUUM CHAMBER ELEMENTS**

VERFAHREN ZUR HERSTELLUNG EINER ALUMINIUMLEGIERUNGSPLATTE FÜR
VAKUUMKAMMERELEMENTE

PROCÉDÉ DE FABRICATION DE PLAQUE D'ALUMINIUM POUR CHAMBRES À VIDE

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Description

CROSS-REFERENCE TO RELATED APPLICATION

- 5 **[0001]** This application claims the benefit of and priority to European Patent Application No. 20179258.7, filed June 10, 2020.

FIELD OF THE INVENTION

- 10 **[0002]** The invention relates to a method of manufacturing an aluminium alloy plate of an Al-Mg-Si alloy (also known as a 6XXX-series aluminium alloy) for forming elements of the vacuum chambers of apparatuses for manufacturing semiconductor devices and liquid crystal devices, such as CVD systems, PVD systems, ion-implanting systems, sputtering systems and dry etching systems, and those placed in the vacuum chambers. The invention relates also to a method of manufacturing vacuum chamber elements from the Al-Mg-Si alloy plate. The invention further relates to methods of manufacturing valves and total assemblies from the Al-Mg-Si alloy plate.

BACKGROUND TO THE INVENTION

- 20 **[0003]** Reactive gases, etching gases, and corrosive gases containing halogen as a cleaning gas are supplied into the vacuum chambers of apparatuses for manufacturing semiconductor devices and liquid crystal devices, such as CVD systems, PVD systems, ion-implanting systems, sputtering systems and dry etching systems. Therefore, the vacuum chambers are required to have corrosion resistance to corrosive gases (hereinafter, referred to as "corrosive gas resistance"). Since a halogen plasma is often produced in the vacuum chamber, resistance to plasmas (hereinafter, referred to as "plasma resistance") is also important. Recently, aluminium and aluminium alloy materials have been used for forming elements of the vacuum chamber because aluminium and aluminium alloy materials are light and excellent in thermal conductivity. Since aluminium and aluminium alloy materials are not satisfactory in corrosive gas resistance and plasma resistance, various surface quality improving techniques for improving those properties have been proposed. However, many of those properties are still unsatisfactory and further improvement of those properties is desired. Coating an aluminium or an aluminium alloy material with a hard anodic oxide film having a high hardness has been found to be effective in improving plasma resistance. The hard anodic oxide film is resistant to the abrasion of a member by a plasma having high physical energy and hence is capable of improving plasma resistance. The vacuum chamber elements require also sufficiently high mechanical strength and elongation, and colour uniformity and a high breakdown voltage after anodization.

- 35 **[0004]** US 2015/0255253 A1 describes aluminum alloy products designed to be used as elements of vacuum chambers. US 2009/0050485 A1 describes an aluminum alloy material and in particular an anodized aluminum alloy material intended for forming members of the vacuum chambers of apparatuses.

- [0005]** US patent document US-2012/0325381-A1 discloses a manufacturing process for a block of aluminium at least 250 mm thick designed for manufacture of an element for a vacuum chamber, the method comprises casting a block of a given 6XXX-series aluminium alloy, optionally homogenizing said cast block, performing a solution heat treatment directly on the cast and optionally homogenized block, quenching the block, stress relieving of the quenched block by means of cold compression, followed by artificial ageing to a T652 condition. A key element of the disclosed process is that prior to the solution heat treatment the block has not been hot or cold worked to reduce its thickness. The resultant plate product is a so-called "cast plate". A disadvantage of cast plate is that the unavoidable phases resulting from the combination and precipitation at grain boundaries of elements like iron, manganese, magnesium, and silicon, often in an eutectic form after solidification, cannot be fully dissolved in the subsequent processing steps like homogenization and solution heat treatment and remain as sites for crack initiation, thus significantly lowering the mechanical properties (e.g., ultimate tensile strength, elongation, toughness, and others), or as initiators of local corrosion (e.g. pitting corrosion) and are harmful also for final treatments like anodization which is of particular relevance for vacuum chamber elements. Any oxide layer present within the cast alloy will also remain in its original shape therefore also lowering the mechanical properties. Although cast plate products might be produced more cost effective, because substantially the as-cast microstructure is maintained, and strongly depends on the local cooling speed during the casting operation, there is much more variation in mechanical properties as function of the testing location as compared to rolled plate products, rendering cast plates less suitable for many critical applications.

- 55 **BRIEF DESCRIPTION OF THE DRAWING**

[0006] Figure 1 is a sample light microscope image for analysing the phases and particles of the aluminium alloy materials described herein.

DESCRIPTION OF THE INVENTION

[0007] As will be appreciated herein below, except as otherwise indicated, aluminium alloy designations and temper designations refer to the Aluminium Association designations in Aluminium Standards and Data and the Registration Records, as published by the Aluminium Association in 2019 and are well known to the person skilled in the art. The temper designations are laid down also in European standard EN515.

[0008] For any description of alloy compositions or preferred alloy compositions, all references to percentages are by weight percent unless otherwise indicated.

[0009] The term "up to" and "up to about", as employed herein, explicitly includes, but is not limited to, the possibility of zero weight-percent of the particular alloying component to which it refers. For example, up to 0.08% Zn may include an aluminium alloy having no Zn.

[0010] It is an object of the invention to provide a method of manufacturing an aluminium alloy plate of an Al-Mg-Si aluminium alloy or 6XXX-series aluminium alloy for forming vacuum chamber elements. It is another object of the invention to provide a method of manufacturing vacuum chamber elements from an Al-Mg-Si aluminium alloy plate. It is a further object of the invention to provide a method of manufacturing valves and total assemblies from the Al-Mg-Si aluminium alloy plate.

[0011] These and other objects and further advantages are met or exceeded by the present invention and providing a method of manufacturing an aluminium alloy plate for vacuum chamber elements, the method comprising the steps of, in this order:

(a) providing a rolling feedstock material of an Al-Mg-Si aluminium alloy having a composition comprising of, in wt.%,

Mg	0.80% to 1.05%;
Si	0.70% to 1.0%;
Mn	0.70% to 0.90%;
Fe	up to 0.20%;
Zn	up to 0.08%, preferably up to 0.05%;
Cu	up to 0.05%, preferably up to 0.03%;
Cr	up to 0.03%, preferably up to 0.02%;
Ti	up to 0.06%, preferably 0.01% to 0.06%;

unavoidable impurities each <0.03%, total <0.10%, balance aluminium;

(b) homogenizing of the rolling feedstock at a temperature in a range of 550°C to 595°C;

(c) hot-rolling of the homogenized rolling feedstock in one or more rolling steps to a hot-rolled plate having a thickness of at least 10 mm;

(d) solution heat-treatment (SHT") of the hot rolled plate at a temperature in a range of 540°C to 590°C;

(e) rapid cooling or quenching of the SHT plate, by one of spray quenching of immersion quenching in water or other quenching media;

(f) stretching of the cooled SHT plate to obtain a permanent elongation from 1% to 5%;

(g) artificial ageing of the stretched plate, wherein the artificial ageing is performed at a temperature in the range of 150°C to 190°C for a time of 5 to 60 hours, preferably to a T6 condition (e.g., T651) or T7 condition (e.g., T7651).

[0012] By the careful control of narrow compositional ranges of the Al-Mg-Si alloy in combination with the thermo-mechanical processing the resultant aluminium alloy plate is ideally suitable for manufacturing vacuum chamber elements. It is available in a wide range of thicknesses and is very good anodizable with a hard anodic coating. The aluminium plate material has high mechanical properties providing good shape stability of the vacuum chamber element. Several properties of an anodized element depend on the plate material's microstructure and composition. The plate product has a microstructure having a uniform distribution of phases within the plate leading to a less affected anodic layer concerning e.g. plate thickness and uniformity at the surface after anodization. The resultant plate product according to this invention provides a high corrosive gas resistance, e.g. as tested in a bubble test using 5% HCl; and has a high breakdown voltage (AC, DC) measured according to ISO-2376(2010).

[0013] In an embodiment the Al-Mg-Si alloy plate at thickness 55 mm in T651 condition has a tensile yield strength (YS) of at least 250 MPa, and even of at least 265 MPa, in the LT-direction in accordance with the applicable norm ISO 6892-1 B.

[0014] In an embodiment the Al-Mg-Si alloy plate at thickness 55 mm in T651 condition has a tensile strength (UTS) of at least 300 MPa, and even of at least 310 MPa, in the LT-direction in accordance with the applicable norm ISO 6892-1 B.

[0015] In an embodiment the Al-Mg-Si alloy plate at thickness 55 mm in T651 condition has an elongation (A_{50mm}) at least 8%, and even of at least 10%, in the LT-direction in accordance with the applicable norm ISO 6892-1 B.

[0016] Mg in combination with Si are the main alloying elements in the aluminium alloy to provide strength by the formation of Mg_2Si phases. The Mg is in a range of 0.80% to 1.05%, and preferably in a range of 0.85% to 1.05%. A preferred upper-limit for the Mg content is 1.0%. A too high Mg content may lead to the formation of coarse Mg_2Si phases having an adverse effect of the quality of a subsequently applied anodization coating. A too low Mg content has an adverse effect on the tensile properties of the aluminium plate.

[0017] The Si is in a range of 0.70% to 1.0%. In an embodiment the Si content is at least 0.75%, preferably at least 0.80%, and most preferably at least 0.84%. In an embodiment the upper-limit for the Si-content is 0.95%.

[0018] In an embodiment the ratio of Mg/Si, in wt. % is more than 0.9, and preferably more than 1.0, and most preferably more than 1.05. Reducing the amount of free Si in the aluminium alloy favours an increased elongation in the aluminium plate after SHT at relative high temperatures as done in accordance with the invention.

[0019] Another important alloying element is Mn and is in a range of 0.70% to 0.90% to increase the strength in the aluminium plate and to control the grain structure and leads recrystallisation after solution heat treatment and quenching. A preferred lower limit is 0.75%. A preferred upper-limit is 0.85%.

[0020] Fe is an impurity element which does not exceed 0.20%. To control grain size and to achieve high mechanical strength and good corrosion resistance after anodization the Fe level is preferably up to 0.12%. However, it is preferred that at least 0.03% is present, and more preferably at least 0.04%. A too low Fe content may lead to undesirable recrystallized grain coarsening and makes the aluminium alloy too expensive. A too high Fe content results in reduced tensile properties and has an adverse effect on for example the breakdown voltage after anodization due to the formation of amongst others $AlFeSi$ phases and has also an adverse effect on the corrosive gas resistance.

[0021] Zn up to 0.08%, Cu up to 0.05%, and Cr up to 0.03% are tolerable impurities and have an adverse effect on the quality of a subsequently applied anodization coating, e.g. reduced corrosive gas resistance. In an embodiment the Zn is up to about 0.05%, and preferably up to about 0.03%. In an embodiment the Cu is up to about 0.03%, and preferably up to about 0.02%. In an embodiment the Cr is up to about 0.02%.

[0022] Ti up to 0.06% is added as a grain refiner of the as-cast microstructure. In an embodiment it is present in a range of about 0.01% to 0.06%, and preferably in a range of about 0.01% to 0.04%.

[0023] Balance is made by aluminium and unavoidable impurities. Impurities are present up to 0.03% each and up to 0.10% total.

[0024] In an embodiment the Al-Mg-Si aluminium alloy has a composition consisting of, in wt.%, Mg 0.80% to 1.05%, Si 0.70% to 1.0%, Mn 0.70% to 0.90%, Fe up to 0.20%, Zn up to 0.08%, Cu up to 0.05%, Cr up to 0.03%, Ti up to 0.06%, unavoidable impurities each up to 0.03%, total up to 0.10%, balance aluminium, and with preferred narrower ranges as herein described and claimed.

[0025] The Al-Mg-Si-Mn aluminium alloy is provided as an ingot or slab for fabrication into a hot rolled plate product by casting techniques regular in the art for cast products, e.g. Direct-Chill (DC)-casting, Electro-Magnetic-Casting (EMC)-casting, Electro-Magnetic-Stirring (EMS)-casting, and preferably having an ingot thickness in a range of about 220 mm or more, e.g. 400 mm, 500 mm or 600 mm. After casting the rolling feedstock, the as-cast ingot is commonly scalped to remove segregation zones near the cast surface of the ingot. Grain refiners such as those containing titanium and boron, or titanium and carbon, are used as is well-known in the art to obtain a fine as-cast grain structure.

[0026] The purpose of a homogenisation heat treatment has at least the following objectives: (i) to dissolve as much as possible coarse soluble phases formed during solidification, and (ii) to reduce concentration gradients to facilitate the dissolution step. A preheat treatment achieves also some of these objectives. The homogenisation process is done a temperature range of 550°C to 595°C. In an embodiment the homogenization temperature is at least 555°C, and more preferably at least 565°C. The soaking time at the homogenisation temperature is in the range of about 1 to 20 hours, and preferably does not exceed about 15 hours, and is more preferably in a range of about 5 to 15 hours. The heat-up rates that can be applied are those which are regular in the art.

[0027] The hot rolling is performed to a hot rolling plate thickness of 10 mm or more. In an embodiment the upper-limit is about 230 mm, preferably about 200 mm and more preferably about 180 mm.

[0028] A next important process step is solution heat treating ("SHT") of the hot rolled plate material. The plate product should be heated to bring as much as possible all or substantially all portions of the soluble alloying elements into solution. The SHT is carried out at a temperature in the temperature range of 540°C to 590°C. A higher SHT temperature provides more favourable mechanical properties, e.g. an increased R_m . In an embodiment the lower-limit for the SHT temperature is 545°C, preferably it is 550°C. In an embodiment the upper-limit for the SHT temperature is about 580°C, and more preferably about 575°C. A low SHT temperature reduces the strength of the aluminium plate and some large Mg_2Si phases main remain undissolved and may create so called "hot spots" and reducing the corrosion resistance after anodization and reduce the breakdown voltage. It is believed that shorter soaking times are very useful, for example in the range of about 10 to 180 minutes, preferably in a range of 10 to 40 minutes, and more preferably in a range of 10 to 35 minutes, for example for plate thicknesses up to 50 mm. A too long soaking time at a relative high SHT temperature results in the growth of several phases adversely affecting the ductility of the aluminium plate. The SHT is typically carried out in a batch or a continuous furnace. After SHT, it is important that the plate material be cooled with a high

cooling rate to a temperature of 100°C or lower, preferably to below 40°C, to prevent or minimise the uncontrolled precipitation of secondary phases. On the other hand cooling rates should preferably not be too high to allow for a sufficient flatness and low level of residual stresses in the plate product. Suitable cooling rates can be achieved with the use of water immersion or water jets.

[0029] The SHT and quenched plate material is further cold worked by means of stretching in the range of about 1% to 5% of its original length to relieve residual stresses therein and to improve the flatness of the plate product. Preferably the stretching is in the range of about 1.5% to 4%, more preferably of about 2% to 3.5%.

[0030] After cooling the stretched plate material is artificially aged, more preferably to provide a T6 condition, more preferably a T651 condition. According to the invention, the artificial ageing is performed at a temperature in the range of 150°C to 190°C, and for a time of 5 to 60 hours.

[0031] In an embodiment the stretch plate material is aged to an over-aged T7 condition, preferably to a T74 or T76 condition, and more preferably to an T7651 condition.

[0032] In a further aspect of the invention it relates to a method of manufacturing a vacuum chamber element, the method comprising the steps of manufacturing the Al-Mg-Si alloy plate having a thickness of at least 10 mm as herein set forth and claimed, and further comprising the subsequent steps of:

(h) machining said aged plate, e.g. in T6, T651, T7, T74, T76, or T7651 condition, into a vacuum chamber element of predetermined shape and dimensions;

(i) surface treating of the vacuum chamber element, preferably by means of anodization; preferably to provide an anode layer or anode coating layer thickness of at least 20 µm, and preferably a thickness of at least 30 µm;

(j) optionally the product thus anodized is hydrated or sealed in deionised water at a temperature of at least 80°C and preferably of at least 98°C, preferably for a duration of at least about 1 hour. In an embodiment the hydration is performed in two steps, a first steps with a duration of at least 10 minutes at a temperature of 30°C to 70°C, and a second step with a duration of at least about 1 hour at a temperature of at least 98°C.

[0033] In an embodiment the anodization is performed using an electrolytic solution comprising at least sulfuric acid at a temperature about 15°C to 30°C and a current density from about 1.0 A/dm² to about 2 A/dm². The acid concentration in the anodizing bath is typically in a range of about 5 to 20 vol.%. The process takes from about 0.5 to 60 minutes, depending on the desired oxide layer thickness. The sulfuric anodizing generally yields an oxide layer with a thickness from about 8 microns to about 40 microns.

[0034] In an embodiment the anodization is performed in an electrolytic solution comprising at least sulfuric acid at a temperature from about 0°C to about 10°C and a current density from about 3 A/dm² to about 4.5 A/dm². The process generally takes from about 20 minutes to about 120 minutes. This hardcoat anodizing generally yields an oxide layer with a thickness from about 30 microns to about 80 microns, or even thicker.

[0035] In some embodiments, the material described herein can have a density of phases and particles having a size greater than 10 µm² or less than 400 per mm². For example, the material can have a density of phases and particles having a size greater than 10 µm² ranging from 100 to 400 per mm² or from 250 to 350 per mm². The phases and particles can include AlFeSi-type phases and particles and Mg₂Si phases and particles.

[0036] The following example will serve to further illustrate the present invention without, however, constituting any limitation thereof. On the contrary, it is to be clearly understood that resort may be had to various embodiments, modifications, and equivalents thereof which, after reading the description herein, may suggest themselves to those of ordinary skill in the art without departing from the spirit of the invention.

EXAMPLE

[0037] Phase analysis experiments were performed on aluminium alloy samples for anodizing as described herein. Three samples of varying thicknesses were investigated, including a sample having a thickness of 130 mm (referred to herein as "Sample 1"), a sample having a thickness of 40 mm (referred to herein as "Sample 2"), and a sample having a thickness of 14 mm (referred to herein as "Sample 3"). Each of the samples was analyzed at three positions, including the near surface position ("surface"), quarter thickness position ("s/4"), and half thickness position ("s/2"). Seven images were captured per position at 1280 x 1024 pixel² (0.382 µm/pixel). As 0.191 mm²/image was analyzed for seven images, approximately 1.34 mm² for each position was investigated, amounting to 12.05 mm² in total. Thus, the samples were extensively studied.

[0038] The images were taken using a light microscope at a magnification of 200x. The samples were prepared in the same manner. No etching was performed. Grinding and polishing was performed for each sample, with special attention paid to avoid any impact on the data due to the preparation method, such as, for example, pores or scratches that could potentially be misinterpreted due to the use of greyscale analyzing tools.

[0039] The phases and particles analyzed were mainly AlFeSi-type phases and particles along with Mg₂Si phases

and particles. The detection was performed using ImageJ software, and the analysis was performed in grayscale. A sample image is shown in Figure 1. A filter was used to only count particles having an area of greater than $10 \mu\text{m}^2$. The results are shown below in Table 1. The density for each position is shown in the column labeled "Density (phases/mm²)," the average density for each sample (calculated by taking the average of the three positions for each sample) is shown in the column labeled "Average Density (phases/mm²)," and the total average density calculated by taking the average of the nine measurements (three samples and three positions per sample) is shown in the column labeled "Total Average Density for All Samples (phases/mm²)." As shown in Table 1, the densities ranged from 250 to 320 phases/mm².

Table 1

Sample	Position	Thickness (mm)	Density (phases/mm ²)	Average Density (phases/mm ²)	Total Average Density for All Samples (phases/mm ²)
Sample 1	surface	130	277.85	276.35	275.86
Sample 1	s/4	130	283.82		
Sample 1	s/2	130	267.39		
Sample 2	surface	40	253.20	257.68	
Sample 2	s/4	40	269.63		
Sample 2	s/2	40	250.21		
Sample 3	surface	14	270.38	293.53	
Sample 3	s/4	14	318.93		
Sample 3	s/2	14	291.29		

[0040] All patents, publications and abstracts cited above are incorporated herein by reference in their entireties. Various embodiments of the invention have been described in fulfillment of the various objectives of the invention. It should be recognized that these embodiments are merely illustrative of the principles of the present invention. Numerous modifications and adaptations thereof will be readily apparent to those skilled in the art without departing from the spirit and scope of the present invention as defined in the following claims.

Claims

1. A method of manufacturing an aluminium alloy plate for vacuum chamber elements, valves, or total assemblies, the method comprising the steps of:

(a) providing a rolling feedstock material of an Al-Mg-Si aluminium alloy having a composition comprising of, in wt.%,

Mg	0.80% to 1.05%,
Si	0.70% to 1.0%,
Mn	0.70% to 0.90%,
Fe	up to 0.20%,
Zn	up to 0.08%,
Cu	up to 0.05%,
Cr	up to 0.03%,
Ti	up to 0.06%,

unavoidable impurities each <0.03%, total <0.10%, balance aluminium;

(b) homogenizing of the rolling feedstock at a temperature in a range of 550°C to 595°C,

(c) hot-rolling of the homogenized rolling feedstock in one or more rolling steps to a hot-rolled plate having a thickness of at least 10 mm;

(d) solution heat-treatment SHT of the hot rolled plate at a temperature in a range of 540°C to 590°C;

(e) rapid cooling the SHT plate, wherein the rapid cooling is performed by one of spray quenching or immersion quenching in water or other quenching media;
 (f) stretching of the cooled SHT plate to obtain a permanent elongation from 1% to 5%; and
 (g) artificial ageing of the stretched plate, wherein the artificial ageing is performed at a temperature in the range of 150°C to 190°C for a time of 5 to 60 hours.

2. The method according to claim 1, wherein the hot rolling of the homogenized rolling feedstock is to a plate having a thickness in the range of 10 mm to 230 mm.

3. The method according to claim 1 or 2, wherein the Mg-content is in a range of 0.85% to 1.05%.

4. The method according to any one of claims 1 to 3, wherein the Si-content is in a range of 0.70% to 0.95%.

5. The method according to any one of claims 1 to 4, wherein the ratio in wt.% Mg/Si is more than 0.9.

6. The method according to any one of claims 1 to 5, wherein the Mn-content is in a range of 0.75% to 0.85%.

7. The method according to any one of claims 1 to 6, wherein the Fe-content is up to 0.12%.

8. The method according to any one of claims 1 to 7, wherein the Ti-content is in a range of 0.01% to 0.06%.

9. The method according to any one of claims 1 to 8, wherein homogenizing of the rolling feedstock is at a temperature in a range of 555°C to 595°C.

10. The method according to any one of claims 1 to 9, wherein the solution heat treatment of the hot rolled plate is at a temperature in a range of 545°C to 580°C.

11. The method according to any one of claims 1 to 10, wherein the artificial ageing is performed to achieve a T6 temper.

12. The method according to any one of claims 1 to 11, further comprising the steps of:

(h) machining said aged plate into a vacuum chamber element, a valve, or a total assembly; and
 (i) surface treating of the vacuum chamber element, the valve, or the total assembly.

13. The method of claim 12, wherein the surface treating is performed by anodization.

14. The method of any one of claims 1 to 13, wherein the aluminum alloy plate has a density of phases and particles having a size greater than 10 μm^2 of less than 400 per mm^2 .

Patentansprüche

1. Verfahren zum Herstellen einer Aluminiumlegierungsplatte für Vakuumkammerelemente, Ventile oder Gesamtanordnungen, wobei das Verfahren die Schritte umfasst:

(a) Bereitstellen eines Walzgutmaterials von einer Al-Mg-Si-Aluminiumlegierung mit einer Zusammensetzung, umfassend in Gew.-%,

Mg	0,80 % bis 1,05 %,
Si	0,70 % bis 1,0 %,
Mn	0,70 % bis 0,90 %,
Fe	bis zu 0,20 %,
Zn	bis zu 0,08 %,
Cu	bis zu 0,05 %,

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(fortgesetzt)

Cr bis zu 0,03 %,
Ti bis zu 0,06%,

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unvermeidbare Verunreinigungen jeweils <0,03 %, insgesamt <0,10 %, Ausgleichsaluminium;
(b) Homogenisieren des Walzguts bei einer Temperatur in einem Bereich von 550°C bis 595°C,
(c) Warmwalzen des homogenisierten Walzguts in einem oder mehreren Walzschritten zu einer warmgewalzten
Platte mit einer Dicke von mindestens 10 mm;
10 (d) Lösungsglühen SHT der warmgewalzten Platte bei einer Temperatur in einem Bereich von 540°C bis 590°C;
(e) rapides Abkühlen der SHT-Platte, wobei das rapide Abkühlen entweder durch Sprühabschrecken oder
Tauchabschrecken in Wasser oder anderen Abschreckmedien erfolgt;
(f) Strecken der gekühlten SHT-Platte, um eine permanente Verlängerung von 1 % bis 5 % zu erhalten; und
(g) künstliche Alterung der gestreckten Platte, wobei die künstliche Alterung bei einer Temperatur in dem Bereich
15 von 150°C bis 190°C für eine Zeit von 5 bis 60 Stunden durchgeführt wird.

2. Verfahren nach Anspruch 1, wobei das Warmwalzen des homogenisierten Walzguts zu einer Platte mit einer Dicke
in dem Bereich von 10 mm bis 230 mm erfolgt.

20 3. Verfahren nach Anspruch 1 oder 2, wobei der Mg-Gehalt in einem Bereich von 0,85 % bis 1,05 % liegt.

4. Verfahren nach einem der Ansprüche 1 bis 3, wobei der Si-Gehalt in einem Bereich von 0,70 % bis 0,95 % liegt.

25 5. Verfahren nach einem der Ansprüche 1 bis 4, wobei das Verhältnis in Gew.-% Mg/Si mehr als 0,9 beträgt.

6. Verfahren nach einem der Ansprüche 1 bis 5, wobei der Mn-Gehalt in einem Bereich von 0,75 % bis 0,85 % liegt.

7. Verfahren nach einem der Ansprüche 1 bis 6, wobei der Fe-Gehalt bis zu 0,12 % beträgt.

30 8. Verfahren nach einem der Ansprüche 1 bis 7, wobei der Ti-Gehalt in einem Bereich von 0,01 % bis 0,06 % liegt.

9. Verfahren nach einem der Ansprüche 1 bis 8, wobei Homogenisieren des Walzguts bei einer Temperatur in einem
Bereich von 555°C bis 595°C erfolgt.

35 10. Verfahren nach einem der Ansprüche 1 bis 9, wobei das Lösungsglühen der warmgewalzten Platte bei einer Tem-
peratur im Bereich von 545°C bis 580°C erfolgt.

11. Verfahren nach einem der Ansprüche 1 bis 10, wobei das künstliche Altern durchgeführt wird, um einen T6-Zustand
zu erreichen.

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12. Verfahren nach einem der Ansprüche 1 bis 11, ferner umfassend die Schritte:

(h) Bearbeiten der gealterten Platte zu einem Vakuumkammerelement, einem Ventil oder einer Gesamtanord-
nung und

45 (i) Oberflächenbehandeln des Vakuumkammerelements, des Ventils oder der Gesamtanordnung.

13. Verfahren nach Anspruch 12, wobei das Oberflächenbehandeln durch Anodisieren durchgeführt wird.

50 14. Verfahren nach einem der Ansprüche 1 bis 13, wobei die Aluminiumlegierungsplatte eine Dichte von Phasen und
Partikeln mit einer Größe von mehr als 10 μm^2 von weniger als 400 pro mm^2 .

Revendications

55 1. Procédé de fabrication d'une tôle en alliage d'aluminium pour des éléments de chambre à vide, des vannes ou des
ensembles totaux, le procédé comprenant les étapes suivantes :

(a) la fourniture d'une matière première de laminage en alliage d'aluminium Al-Mg-Si présentant une composition

comprenant, en % en poids,

	Mg	0,80 % à 1,05 %,
5	Si	0,70 % à 1,0 %,
	Mn	0,70 % à 0,90 %,
	Fe	jusqu'à 0,20 %,
	Zn	jusqu'à 0,08 %,
	Cu	jusqu'à 0,05 %,
10	Cr	jusqu'à 0,03 %,
	Ti	jusqu'à 0,06 %,

des impuretés inévitables, chacune < 0,03 %, total < 0,10 %, le reste étant de l'aluminium ;

15 (b) l'homogénéisation de la matière première de laminage à une température dans une plage de 550 °C à 595 °C, (c) le laminage à chaud de la matière première de laminage homogénéisée dans une ou plusieurs étapes de laminage pour obtenir une tôle laminée à chaud ayant une épaisseur d'au moins 10 mm ;

(d) un traitement thermique de mise en solution SHT de la tôle laminée à chaud à une température dans une plage de 540 °C à 590 °C ;

20 (e) le refroidissement rapide de la tôle SHT, dans lequel le refroidissement rapide est effectué par une trempe par pulvérisation ou une trempe par immersion dans l'eau ou un autre milieu de trempe ;

(f) l'étirage de la tôle SHT refroidie pour obtenir un allongement permanent de 1 % à 5 % ; et

(g) le vieillissement artificiel de la tôle étirée, dans lequel le vieillissement artificiel est effectué à une température dans la plage de 150 °C à 190 °C pendant une durée de 5 à 60 heures.

25 2. Procédé selon la revendication 1, dans lequel le laminage à chaud de la matière première de laminage homogénéisée est pour obtenir une tôle présentant une épaisseur dans la plage de 10 mm à 230 mm.

3. Procédé selon la revendication 1 ou 2, dans lequel la teneur en Mg est dans une plage de 0,85 % à 1,05 %.

30 4. Procédé selon l'une quelconque des revendications 1 à 3, dans lequel la teneur en Si est dans une plage de 0,70 % à 0,95 %.

5. Procédé selon l'une quelconque des revendications 1 à 4, dans lequel le rapport Mg/Si en % en poids est supérieur à 0,9.

35 6. Procédé selon l'une quelconque des revendications 1 à 5, dans lequel la teneur en Mn est dans une plage de 0,75 % à 0,85 %.

40 7. Procédé selon l'une quelconque des revendications 1 à 6, dans lequel la teneur en Fe va jusqu'à 0,12 %.

8. Procédé selon l'une quelconque des revendications 1 à 7, dans lequel la teneur en Ti est dans une plage de 0,01 % à 0,06 %.

45 9. Procédé selon l'une quelconque des revendications 1 à 8, dans lequel l'homogénéisation de la matière première de laminage est à une température dans une plage de 555 °C à 595 °C.

50 10. Procédé selon l'une quelconque des revendications 1 à 9, dans lequel le traitement thermique de mise en solution de la tôle laminée à chaud est à une température dans une plage de 545 °C à 580 °C.

11. Procédé selon l'une quelconque des revendications 1 à 10, dans lequel le vieillissement artificiel est effectué pour obtenir un revenu T6.

55 12. Procédé selon l'une quelconque des revendications 1 à 11, comprenant en outre les étapes suivantes :

(h) l'usinage de ladite tôle vieillie pour obtenir un élément de chambre à vide, une vanne ou un ensemble

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complet ; et

(i) le traitement de surface de l'élément de chambre à vide, de la vanne ou de l'ensemble complet.

13. Procédé selon la revendication 12, dans lequel le traitement de surface est effectué par anodisation.

14. Procédé selon l'une quelconque des revendications 1 à 13, dans lequel la tôle en alliage d'aluminium présente une densité de phases et de particules présentant une taille supérieure à $10 \mu\text{m}^2$ inférieure à 400 phases par mm^2 .

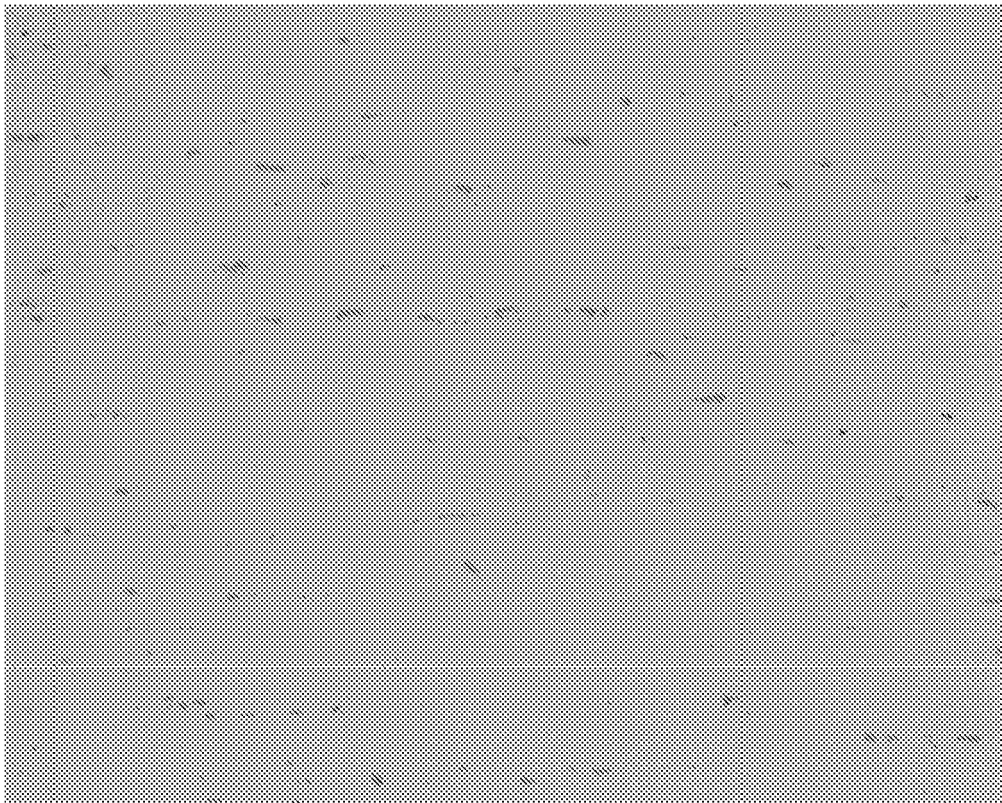


FIGURE 1

REFERENCES CITED IN THE DESCRIPTION

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